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Metal-free introduction of primary sulfonamide into electron-rich aromatics†

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We report herein a direct and practical synthesis of arylsulfonamides from electron-rich aromatic compounds by using *in situ* generated *N*-sulfonylamine as the active electrophile. Substrates include derivatives of aniline, indole, pyrrole, furan, styrene and so on. The reaction proceeds under mild conditions and tolerates many sensitive functional groups such as alkyne, acetate, the trifluoromethoxy group or acetoxymethyl ester. Applications of this method for the construction of metal ion sensors and fluorogenic dye have been demonstrated, thus highlighting the potential of this method for probe development.

Introduction

Primary sulfonamides R-SO₂NH₂ are abundant in pharmaceutical compounds,¹ dyes,² catalysts,^{3,4} polymers⁵ and other structures.^{6–9} For example, by incorporating sulfonamide into classical rhodamine dyes, our group reported a general strategy in 2020 for making cell-permeable and fluorogenic probes (so-called ‘MaP’-dyes, Scheme 1A).^{10,11} Based on this design, we further reported a semi-synthetic calcium sensor in 2022 by combining the known calcium chelator BAPTA [1,2-bis(*o*-aminophenoxy)ethane-*N,N,N',N'*-tetraacetic acid] with rhodamine dyes through a sulfonamide linkage.¹²

However, a conventional method for sulfonamide synthesis was performed under strong acidic/basic conditions using a chlorosulfonic acid – ammonia sequence (Scheme 1B), which forced us to take a nine-step synthetic route with multiple protection/deprotection steps for the synthesis of **1**. Meanwhile we were also interested in developing a potassium sensor using the MaP dye strategy, but the synthetic efficiency for accessing sulfonamide **2** with the conventional method was too low (0–1% yield). Considering the importance of the sulfonamide group in medicinal chemistry, novel SO₂ surrogates have been developed for accessing sulfonamides, including: DABSO [DABCO·(SO₂)₂] from the Willis group (2011);¹³ potassium metabisulfite from the Wu group (2012);¹⁴ tetrabromothiophene *S,S*-dioxide from the Lian group (2021).^{15–17} More recently, sulfonamides were also prepared from carboxylic acids by using a photocatalytic decarboxylative process, as reported by the Larionov group, the

MacMillan group, the Willis group and the Zhang/Yang group independently.^{18–21} Despite these advances, pre-functionalized substrates were required in most cases (Scheme 1C).^{22–34} An electrochemical process for direct sulfonamide synthesis was reported in 2021 by the Waldvogel group, but primary sulfonamides were not accessed.³⁵ These limitations motivated us to develop a direct method for the introduction of primary sulfonamide group into aromatic compounds.

While searching for an alternative route, we were intrigued by the structure of the Burgess reagent,³⁶ a mild dehydrating reagent as well as a sulfamoylation reagent for the synthesis of sulfamate^{37,38} or sulfamide.^{39–41} Recently it has also been used for preparing sulfonamide, but functional group tolerance was limited since an organometallic reagent or Lewis acid/heating was needed for activation.^{42–44} In fact, *N*-sulfonylamine (or aza-sulfene) was proposed in Burgess's early report as an elusive intermediate for the preparation of the Burgess reagent, and trapping it with nucleophiles such as amine or alkene to form sulfamide or a cycloadduct was successfully demonstrated.^{45,46} However, *N*-sulfonylamine was only detected and characterized by matrix-isolation IR spectroscopy in 2016, largely due to its high instability.⁴⁷ Although its applications in synthetic chemistry were still limited, we envisioned that *N*-sulfonylamine could be a better electrophile than the Burgess reagent for making sulfonamides, in a similar way to sulfur trioxide for accessing sulfonic acids (Scheme 1D).

Results and discussion

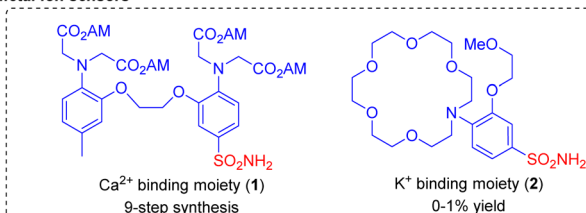
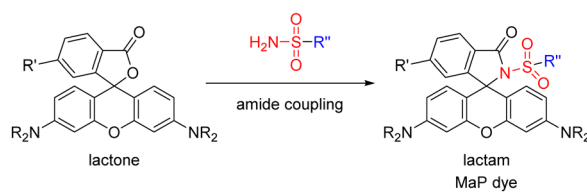
We therefore explored the possibility of using *in situ* generated *N*-sulfonylamine for direct sulfonamide synthesis. *N,N*-dimethylaniline **3a** was selected as a model substrate and ClSO₂-NH₂Boc as an *N*-sulfonylamine precursor (Table 1). To our pleasure, formation of Boc-protected sulfonamide **4a** at the *para/ortho* position was observed when treating a solution of **3a**

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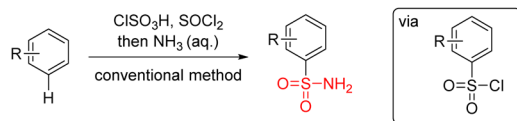
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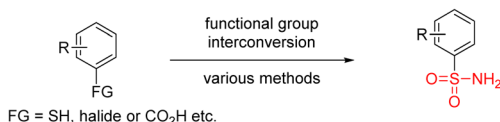
A. Our interest in the use of sulfonamides for making fluorogenic probes and metal ion sensors



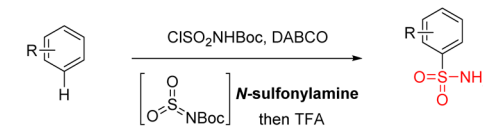
B. Classical way of synthesizing sulfonamides



C. Recent development in sulfonamide synthesis



FG = SH, halide or CO₂H etc.

D. This work: direct synthesis of arylsulfonamides with *N*-sulfonylamine*N*-sulfonylamine:

1967, first studied by Burgess, unstable, tend to polymerize stabilized with base as inner salt (Burgess Reagent)
2016, detected and characterized with IR
2020, application in sulfamoylation with alcohols

Scheme 1 Our previous work using sulfonamides for fine-tuning rhodamine properties and further applications in creating metal ion sensors (A). Traditional methods for sulfonamide synthesis (B). Synthesis of sulfonamides from pre-functionalized substrates (C). This work using *N*-sulfonylamine for direct access to sulfonamides from electron-rich aromatic compounds (D).

Table 1 Optimization of the reaction conditions^a

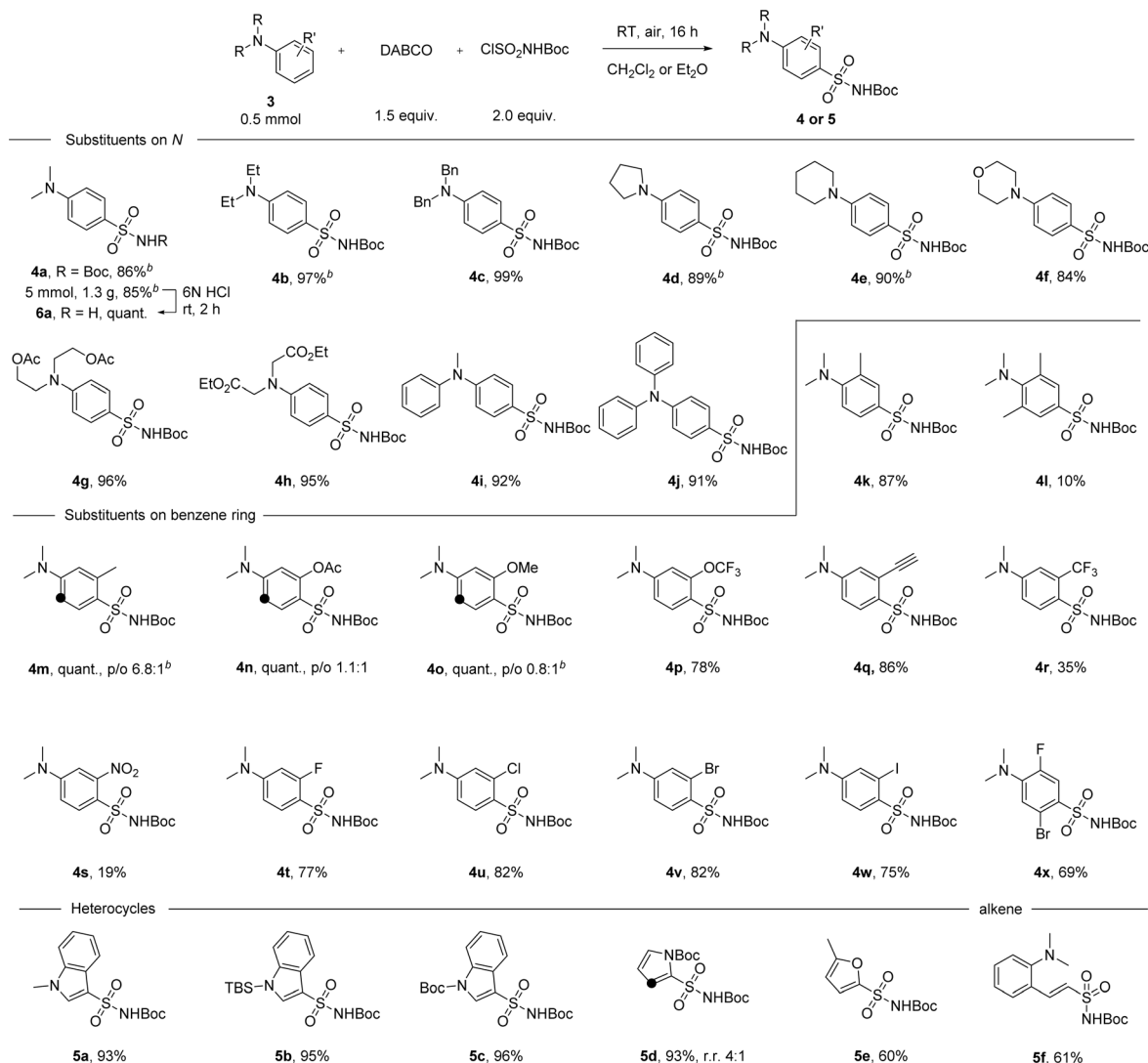
Entry	Additive	Solvent	Conversion ^b (%)	<i>p/o</i> ratio
1	DABCO	Et ₂ O	92	17 : 1
2	Et ₃ N	Et ₂ O	80	3.6 : 1
3	Pyridine	Et ₂ O	20	3.8 : 1
4	DBU	Et ₂ O	25	5 : 1
5	Na ₂ CO ₃	Et ₂ O	20	2.5 : 1
6	DABCO	CH ₂ Cl ₂	98	2.6 : 1
7	—	Et ₂ O	7	—
8	AlCl ₃ /TMSOTf ^c	CH ₂ Cl ₂	<5	—

^a Reaction conditions: reactions were run at a 0.10 mmol scale in 1.0 mL of solvent at room temperature for 4 h. Boc = CO₂*t*-Bu. ^b The conversion was determined by crude ¹H NMR after an aqueous workup. ^c Only 0.1 equivalent of Lewis acid was used.

and a base with ClSO₂NHBoc at room temperature for the *in situ* formation of *N*-sulfonylamine. Among the tested organic bases, DABCO gave the highest conversion as well as *para/ortho* selectivity (Table 1, entries 1–4). An inorganic base like Na₂CO₃ gave products in poor yield and selectivity (Table 1, entry 5). In comparison to diethyl ether, dichloromethane as a solvent can further improve the conversion, albeit with lower *para/ortho* selectivity (Table 1, entry 6). In contrast, only 7% of **3a** was consumed in the absence of a base while the rest was found to be protonated, which was then restored after a basic aqueous workup (Table 1, entry 7). Lewis acid additives such as AlCl₃ or TMSOTf were unable to catalyze this Friedel-Crafts type reaction (Table 1, entry 8), which was not surprising since it has

always been a challenge for aniline derivatives to participate in other electrophilic aromatic substitution reactions like alkylation^{48–53} or acylation.⁵⁴ Switching from *N*-sulfonylamine to the Burgess reagent led to a lower conversion of **3a**, while the DABCO based inner salt showed no reactivity (see ESI, Scheme S1†).

With the optimal conditions in hand, we then examined the scope of the reaction with either diethyl ether or dichloromethane as the solvent (Scheme 2). *Para*-substituted sulfonamide **4a** was obtained in 86% yield and the synthesis can be easily scaled up, delivering 1.3 grams of the product without losing efficiency. Facile removal of the Boc group was achieved by treating **4a** with 6 N HCl solution at room temperature for 2 hours, and the primary sulfonamide **6a** was obtained quantitatively by filtration after neutralization. Anilines with cyclic or acyclic alkyl substituents on the nitrogen atom underwent the reaction well to give products **4b–h** in yields ranging between 84 and 99%. This reaction was extended successfully to diphenylmethanamine and triphenylamine, with products **4i–j** isolated in 91–92% yield. No erosion of the reactivity was observed with just one methyl group at the *ortho* position, but the conversion rate dropped to 10% when *ortho* positions were both occupied (products **4k–l**). Substituents at the *meta* position, especially electron-donating groups, were found to have a strong impact on *para/ortho* selectivity. On switching from a methyl group to acetate or to a methoxy group, though the yield was not affected, the ratio of the *ortho*-substituted product gradually increased even when Et₂O was used as the solvent (products **4m–o**). With electron-withdrawing substituents at the *meta* position, the *para*-substituted product was obtained as the major product. For example, in the case of the trifluoromethoxy group, *para*-substituted **4p** was isolated in 78% yield. A series of functional groups including alkynyl, trifluoromethyl and the strongly

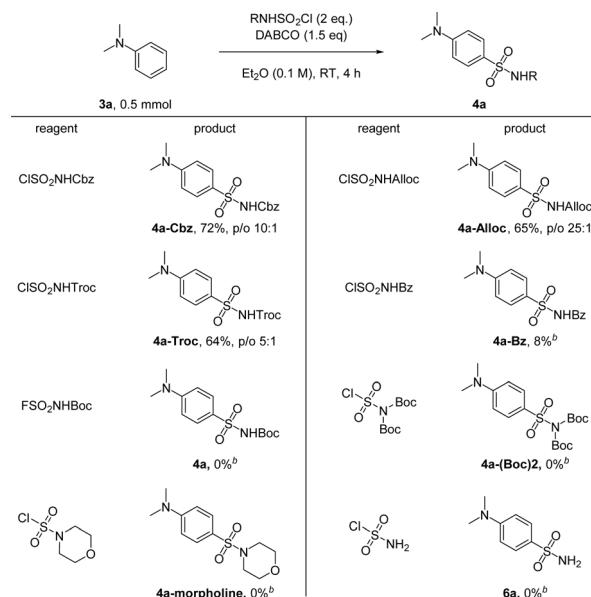


Scheme 2 Scope of aromatic compounds in the direct sulfonamide synthesis. ^[a]Reaction conditions: **3** (0.50 mmol), DABCO (0.75 mmol), ClSO₂NHBoc (1.0 mmol), in CH₂Cl₂ (5.0 mL) at room temperature for 16 hours. Black dots indicated other reactive sites where regioisomers were formed. In all cases, regioisomers were easily separated from each other by flash column chromatography, except in the case of **5d**. ^[b] Et₂O (5.0 mL) was used as solvent.

electron-withdrawing nitro group were well tolerated, giving the corresponding products in 19–86% yield (products **4q–s**). Substrates with one or more halogen atoms can also be tolerated and products **4t–x** were obtained in 69–82% yield. Apart from aniline derivatives, other electron-rich aromatic compounds like indole or pyrrole with various substituents on the *N* atom were also tested under standard conditions and excellent yields were obtained in these cases (products **5a–d**). Furan can participate in the reaction as well, with product **5e** isolated in 60% yield. When a vinyl group was present in the substrate, the reaction took place first at the vinyl position before the aryl substitution happened (product **5f**). However, efforts to further extend the reaction scope to include less electron-rich substrates, such as anisole, chlorobenzene, or azobenzene, were not successful (see ESI, Scheme S3†).

With our interest in developing semi-synthetic fluorescent sensors, we then applied this reaction for introducing

sulfonamide group into metal-ion binding moieties (Scheme 3). A simple substrate containing acetoxymethyl ester (AM ester) **7** was tested first, giving the desired product **8** in 85% yield. Combining this step with Boc deprotection in a one-pot fashion by adding TFA to the reaction crude was also successful, and primary sulfonamide **9** was isolated in 80% yield. We then moved forward to test this reaction on the commercially available calcium chelator BAPTA-AM ester **10**. Gratifyingly sulfonamide **11** was obtained in 53% yield with this two-step sequence, which greatly reduced synthetic steps as compared to the previously reported nine-step route for accessing sulfonamide **1**.¹² Encouraged by this result, we further synthesized sulfonamides **13** and **15**, which can be used for making zinc ion and magnesium ion fluorescent sensors respectively.^{55–57} Performing this reaction on the aza-crown ether **16**, a chelator favors coordination to potassium ions over other metal ions,^{58–61}



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fluorescent images are available at <http://zenodo.org>, DOI: <http://doi.org/10.5281/zenodo.10683729>.

Author contributions

K. J. directed the research. M.-M. W. designed and performed the experiments. K. J. and M.-M. W. wrote the manuscript together.

Conflicts of interest

The authors declare no conflict of interest.

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Notes and references

- 1 A. Ovung and J. Bhattacharyya, *Biophys. Rev.*, 2021, **13**, 259–272.
- 2 H. E. Gaffer, *Color. Technol.*, 2019, **135**, 484–500.
- 3 Y.-R. Zhu, J. Xu, H.-F. Jiang, R.-J. Fang, Y.-J. Zhang, L. Chen, C. Sun and F. Xiong, *Eur. J. Org. Chem.*, 2022, **2022**, e202201081.
- 4 H. Tanaka, K. Sakai, A. Kawamura, K. Oisaki and M. Kanai, *Chem. Commun.*, 2018, **54**, 3215–3218.
- 5 M. Odnoroh, J.-D. Marty, V. Bourdon, O. Coutelier and M. Destarac, *Polym. Chem.*, 2023, **14**, 3821–3826.
- 6 A. U. Augustin, P. G. Jones and D. B. Werz, *Chem.–Eur. J.*, 2019, **25**, 11620–11624.
- 7 P. S. Fier and K. M. Maloney, *J. Am. Chem. Soc.*, 2019, **141**, 1441–1445.
- 8 A. Gómez-Palomino and J. Cornella, *Angew. Chem., Int. Ed.*, 2019, **58**, 18235–18239.
- 9 M. J. Tilby, D. F. Dewez, L. R. E. Pantaine, A. Hall, C. Martínez-Lamenca and M. C. Willis, *ACS Catal.*, 2022, **12**, 6060–6067.
- 10 L. Wang, M. Tran, E. D'Este, J. Roberti, B. Koch, L. Xue and K. Johnsson, *Nat. Chem.*, 2020, **12**, 165–172.
- 11 N. Lardon, L. Wang, A. Tschanz, P. Hoess, M. Tran, E. D'Este, J. Ries and K. Johnsson, *J. Am. Chem. Soc.*, 2021, **143**, 14592–14600.
- 12 N. Mertes, M. Busch, M.-C. Huppertz, C. N. Hacker, J. Wilhelm, C.-M. Gürth, S. Kühn, J. Hiblot, B. Koch and K. Johnsson, *J. Am. Chem. Soc.*, 2022, **144**, 6928–6935.
- 13 H. Woolven, C. González-Rodríguez, I. Marco, A. L. Thompson and M. C. Willis, *Org. Lett.*, 2011, **13**, 4876–4878.
- 14 A. Tota, S. St John-Campbell, E. L. Briggs, G. O. Estévez, M. Afonso, L. Degennaro, R. Luisi and J. A. Bull, *Org. Lett.*, 2018, **20**, 2599–2602.
- 15 X. Marset, J. Torregrosa-Crespo, R. M. Martínez-Espinoza, G. Guillena and D. J. Ramón, *Green Chem.*, 2019, **21**, 4127–4132.
- 16 Y. Li, M. Wang and X. Jiang, *Chin. J. Chem.*, 2020, **38**, 1521–1525.
- 17 X. Wang, M. Yang, Y. Kuang, J.-B. Liu, X. Fan and J. Wu, *Chem. Commun.*, 2020, **56**, 3437–3440.
- 18 S. Mkrtchyan and V. O. Iaroshenko, *Chem. Commun.*, 2021, **57**, 11029–11032.
- 19 S. E. Gatarz, O. M. Griffiths, H. A. Esteves, W. Jiao, P. Morse, E. L. Fisher, D. C. Blakemore and S. V. Ley, *J. Org. Chem.*, 2024, **89**, 1898–1909.
- 20 M. Zhang, L. Liu, B. Wang, Y. Yang, Y. Liu, Z. Wang and Q. Wang, *ACS Catal.*, 2023, **13**, 11580–11588.
- 21 T. Q. Davies, M. J. Tilby, D. Skolc, A. Hall and M. C. Willis, *Org. Lett.*, 2020, **22**, 9495–9499.
- 22 S. Tummanapalli, S. Bodige, K. C. Gulipalli, S. Endoori, S. Medaboina and K. Mallidi, *Tetrahedron Lett.*, 2022, **97**, 153781.
- 23 S. P. Blum, T. Karakaya, D. Schollmeyer, A. Klapars and S. R. Waldvogel, *Angew. Chem., Int. Ed.*, 2021, **60**, 5056–5062.
- 24 E. M. Burgess, H. R. Penton, Jr and E. A. Taylor, *J. Am. Chem. Soc.*, 1970, **92**, 5224–5226.
- 25 I. Armitage, A. M. Berne, E. L. Elliott, M. Fu, F. Hicks, Q. McCubbin and L. Zhu, *Org. Lett.*, 2012, **14**, 2626–2629.
- 26 P. B. Rapp, K. Murai, N. Ichiishi, D. K. Leahy and S. J. Miller, *Org. Lett.*, 2020, **22**, 168–174.

- 39 J.-Y. Winum, L. Toupet, V. Barragan, G. Dewynter and J.-L. Montero, *Org. Lett.*, 2001, **3**, 2241–2243.
- 40 H.-M. Wang, C.-D. Xiong, X.-Q. Chen, C. Hu and D.-Y. Wang, *Org. Lett.*, 2021, **23**, 2595–2599.
- 41 M. A. Sguazzin, J. W. Johnson and J. Magolan, *Org. Lett.*, 2021, **23**, 3373–3378.
- 42 J. M. Young, A. G. Lee, R. Y. Chandrasekaran and J. W. Tucker, *J. Org. Chem.*, 2015, **80**, 8417–8423.
- 43 S. Vijayaradhi, R. Srinivas, U. Ramesh, K. Chandra Prakash and K. Sathish, *Results Chem.*, 2022, **4**, 100467.
- 44 S. Vijayaradhi, V. Muralikrishna, R. Srinivas, C. P. K. Rao, K. Y. Prasad, B. Prasad and B. Khanna, *Results Chem.*, 2023, **5**, 100754.
- 45 G. M. Atkins and E. M. Burgess, *J. Am. Chem. Soc.*, 1967, **89**, 2502–2503.
- 46 G. M. Atkins, Jr and E. M. Burgess, *J. Am. Chem. Soc.*, 1968, **90**, 4744–4745.
- 47 G. Deng, Z. Wu, D. Li, R. Linguerri, J. S. Francisco and X. Zeng, *J. Am. Chem. Soc.*, 2016, **138**, 11509–11512.
- 48 X. Hu, D. Martin, M. Melaimi and G. Bertrand, *J. Am. Chem. Soc.*, 2014, **136**, 13594–13597.
- 49 W. Li and T. Werner, *Org. Lett.*, 2017, **19**, 2568–2571.
- 50 K. Naksomboon, J. Poater, F. M. Bickelhaupt and M. Á. Fernández-Ibáñez, *J. Am. Chem. Soc.*, 2019, **141**, 6719–6725.
- 51 S. Wang, G. Force, R. Guillot, J.-F. Carpentier, Y. Sarazin, C. Bour, V. Gandon and D. Lebœuf, *ACS Catal.*, 2020, **10**, 10794–10802.
- 52 I. Colomer, *ACS Catal.*, 2020, **10**, 6023–6029.
- 53 L. Winfrey, L. Yun, G. Passeri, K. Suntharalingam and A. P. Pulis, *Chem.–Eur. J.*, 2024, **30**, e202303130.
- 54 S. Kobayashi, I. Komoto and J.-i. Matsuo, *Adv. Synth. Catal.*, 2001, **343**, 71–74.
- 55 K. R. Gee, Z. L. Zhou, D. Ton-That, S. L. Sensi and J. H. Weiss, *Cell Calcium*, 2002, **31**, 245–251.
- 56 J. Zhang, X. Peng, Y. Wu, H. Ren, J. Sun, S. Tong, T. Liu, Y. Zhao, S. Wang, C. Tang, L. Chen and Z. Chen, *Angew. Chem., Int. Ed.*, 2021, **60**, 25846–25855.
- 57 M. Liu, X. Yu, M. Li, N. Liao, A. Bi, Y. Jiang, S. Liu, Z. Gong and W. Zeng, *RSC Adv.*, 2018, **8**, 12573–12587.
- 58 S. Ast, T. Schwarze, H. Müller, A. Sukhanov, S. Michaelis, J. Wegener, O. S. Wolfbeis, T. Körzdörfer, A. Dürkop and H.-J. Holdt, *Chem.–Eur. J.*, 2013, **19**, 14911–14917.
- 59 T. Hirata, T. Terai, H. Yamamura, M. Shimonishi, T. Komatsu, K. Hanaoka, T. Ueno, Y. Imaizumi, T. Nagano and Y. Urano, *Anal. Chem.*, 2016, **88**, 2693–2700.
- 60 J. Ning and Y. Tian, *Sens. Actuators, B*, 2020, **307**, 127659.
- 61 Z. Wang, T. C. Detomasi and C. J. Chang, *Chem. Sci.*, 2021, **12**, 1720–1729.
- 62 G. M. Atkins, Jr and E. M. Burgess, *J. Am. Chem. Soc.*, 1972, **94**, 6135–6141.

